



The
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EEE6212

“Semiconductor Materials” -Assignment

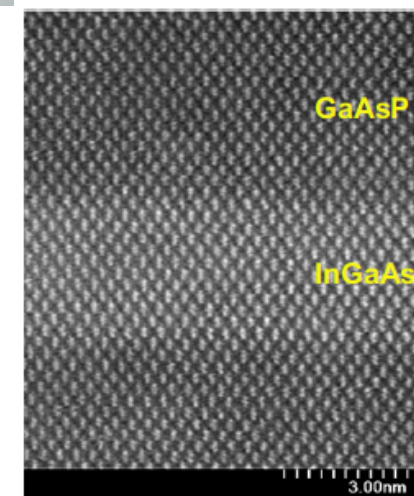
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Introduction

- Discuss need for characterisation of epitaxial materials
- Focus on combination of photoluminescence and X-Ray diffraction
- Discuss both
- Introduce samples you will study
- How, where, when

Motivation

- Advanced semiconductor structures are realised via epitaxial processes
- Structures have varying alloy compositions, doping, thickness (mono-layer precision)
- Need methods to characterise deposited materials
- In manufacturing – non-destructive characterisation is required
- PL and X-ray diffraction are a complementary set of methods



Photoluminescence (PL)

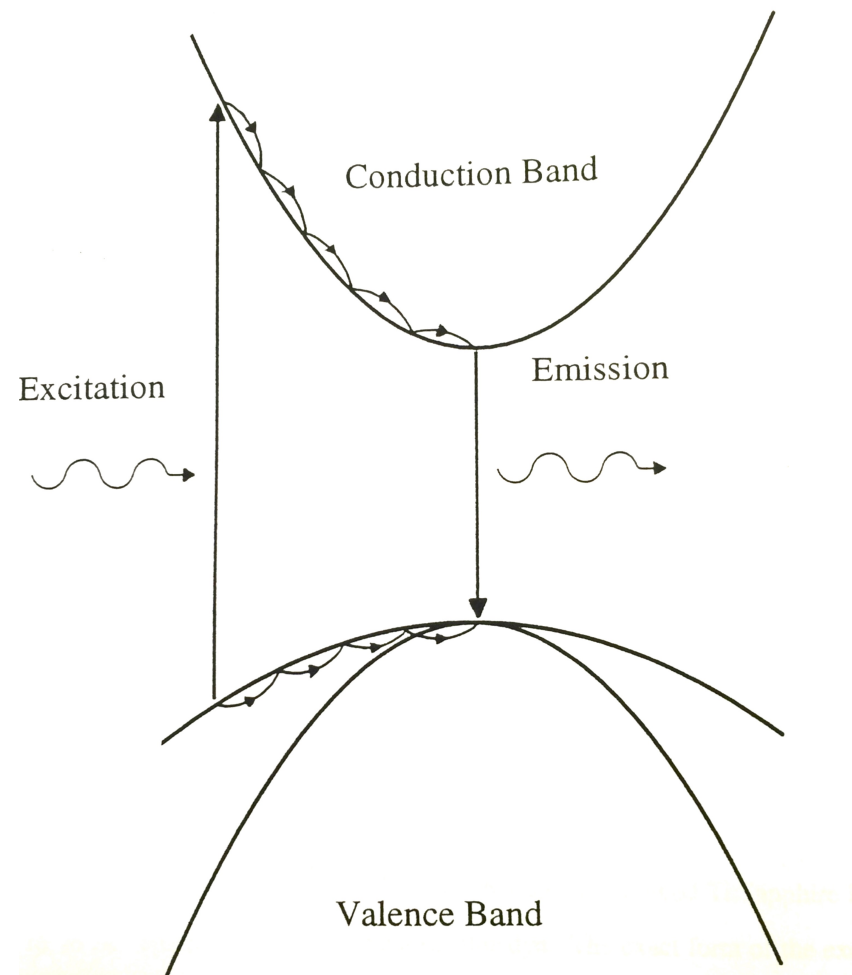
3 step process

Excitation – above band-gap light creates electrons and holes

Relaxation – electron (hole) relaxes to conduction band minimum (valence band maxima)

Emission – the electron and hole recombine through spontaneous emission

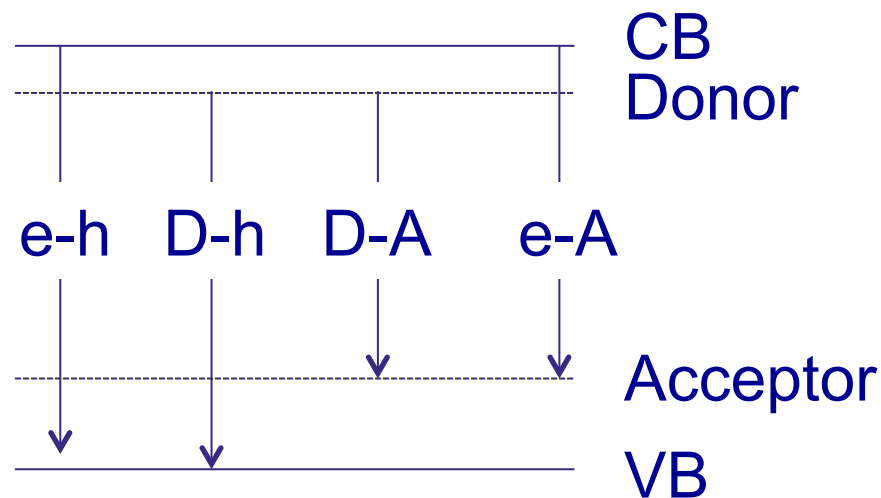
Provides a direct measure of the band-gap (caveats to this over the page!)



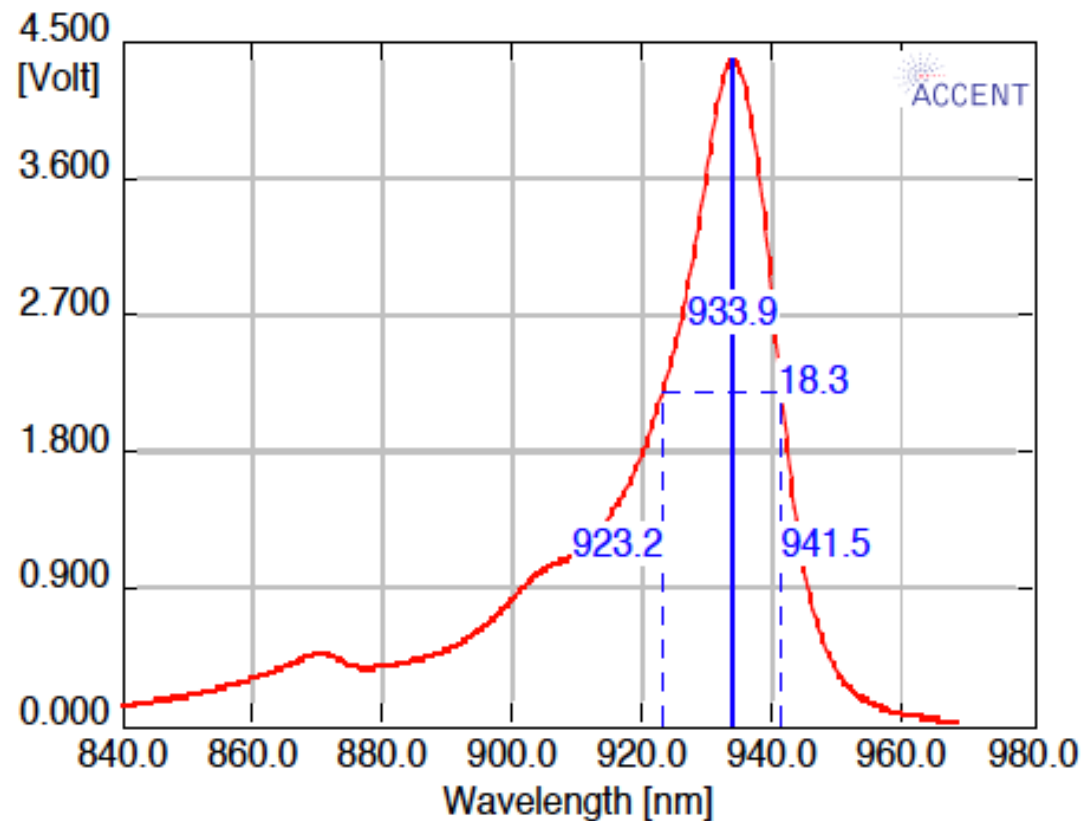
PL – Band-gap Caveats.....

Excitons ? Depending upon the band-gap and the temperature, excitons have a lower energy than the band-gap. At room temperature – not a problem for GaAs, InP.

Donors, Acceptor ?



Room Temperature Line-shape

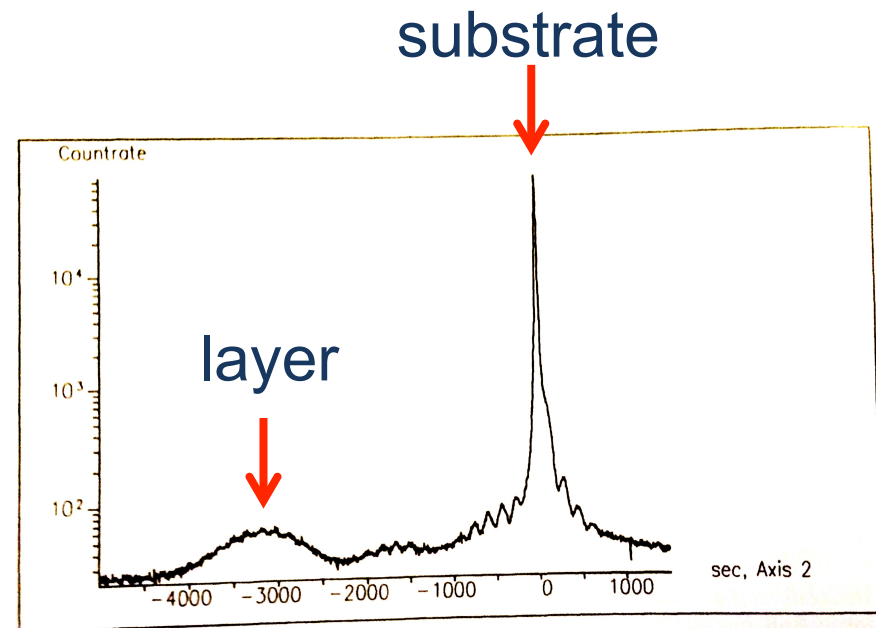


Lineshape is a convolution of Boltzmann Fn and Gaussian (See paper)

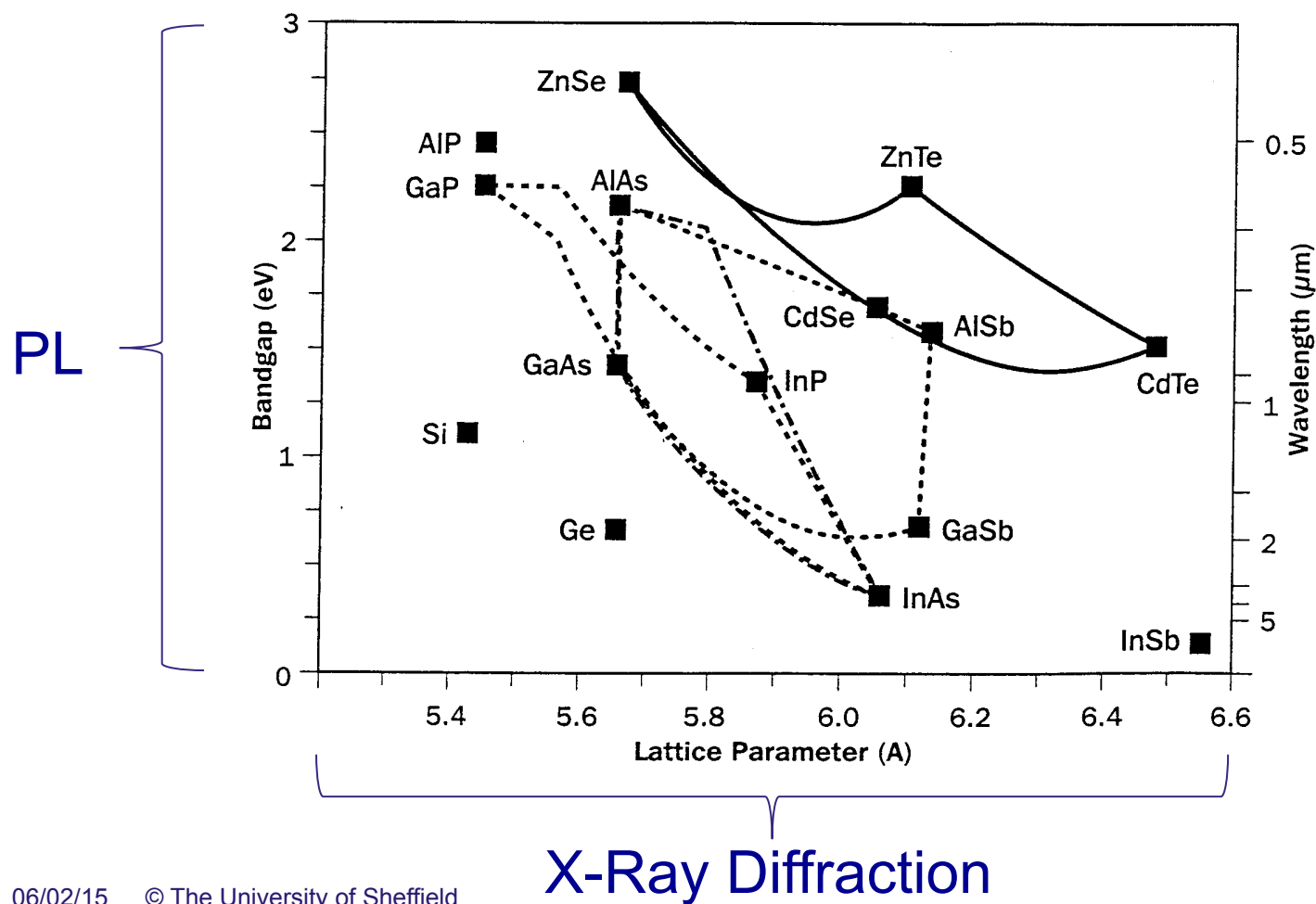
Other features from other states (GaAs band-edge, higher order states in QW...)

X-Ray Diffraction – Bulk

- See previous lecture...
XRD tells you many things about the deposited layers
- Critically - provides a measure of the lattice constants in-plane and out-of plane



PL and X-Ray - Bulk

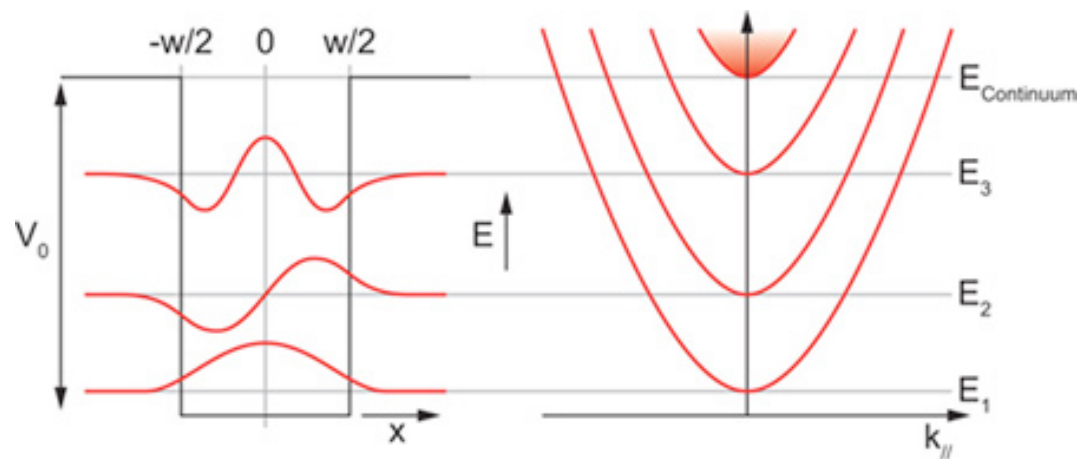


The Quantum Well

(We will do this in more detail later...)

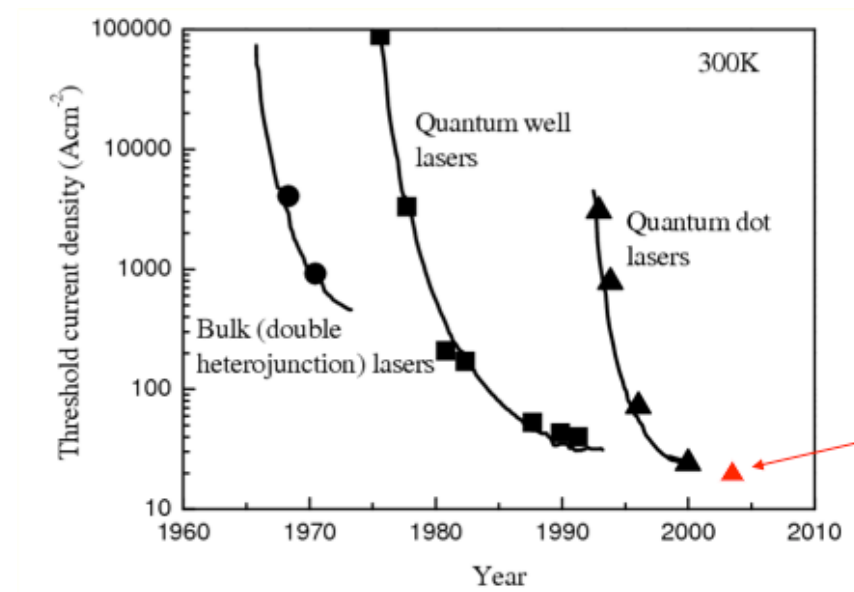
QW - Semiconductor structure which creates a potential on the length scale of the De Broglie wavelength of the electron

- Lowest energy state no longer from band-edge
 - Quantum confinement
- Energy depends upon depth and width of quantum well



QW – Why care?

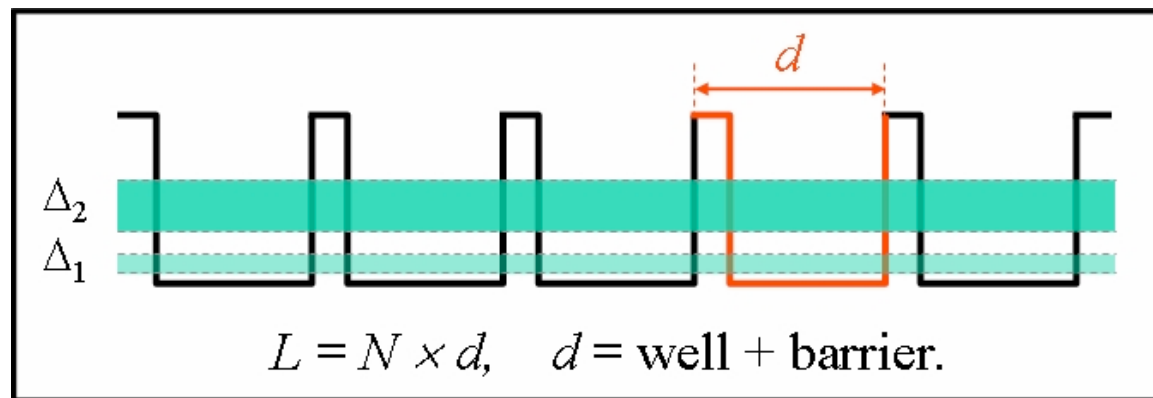
- At the heart of every semiconductor laser
- Many transistors enabled by QWs
- State-of-the-art solar cells...



Liu et al.

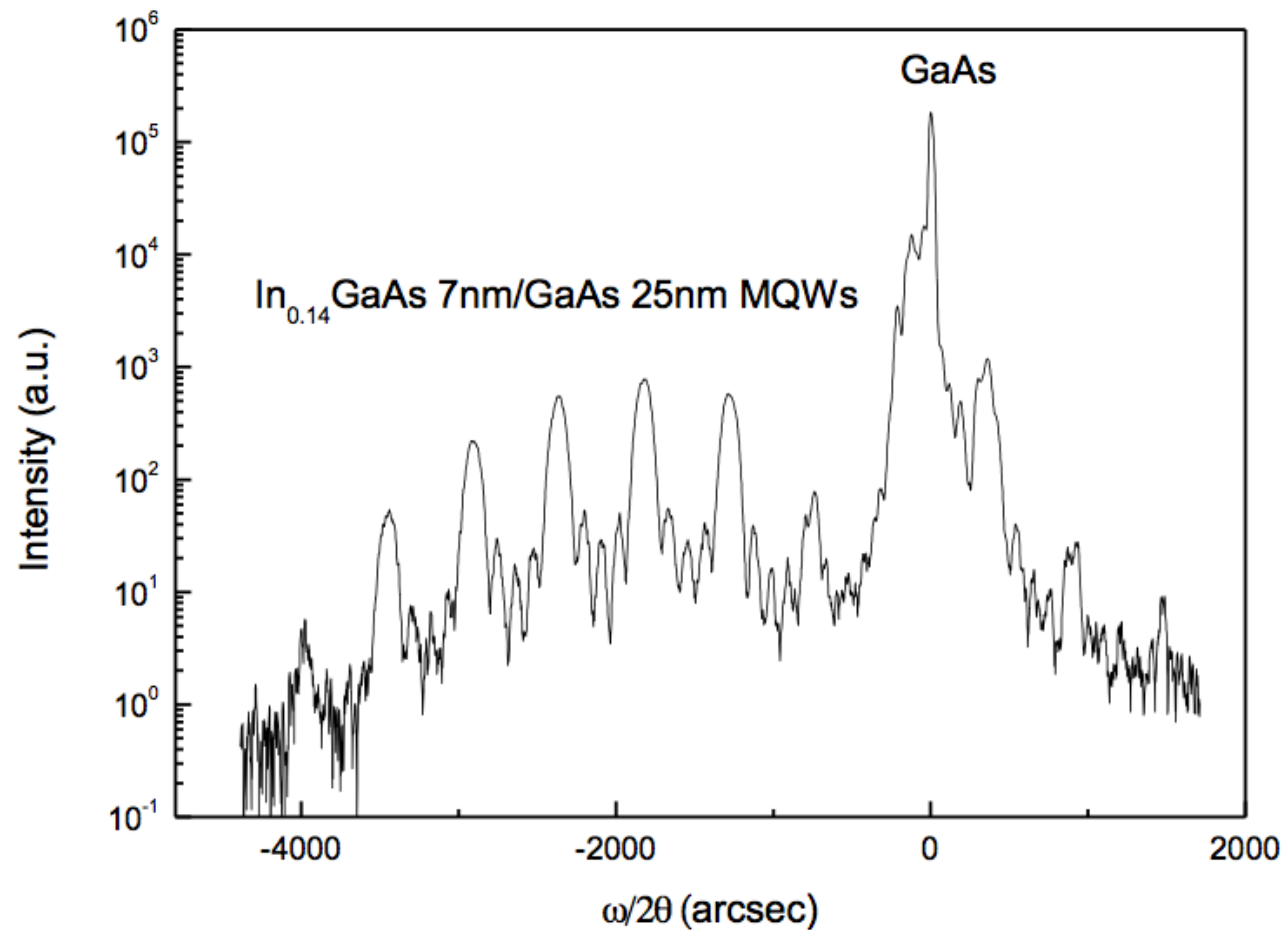
n.b. The Term “Superlattice”

- Crystallography – multiple layers A/B/A/B.....
- Quantum mechanics – analogous to a crystal lattice – short period quantum well with

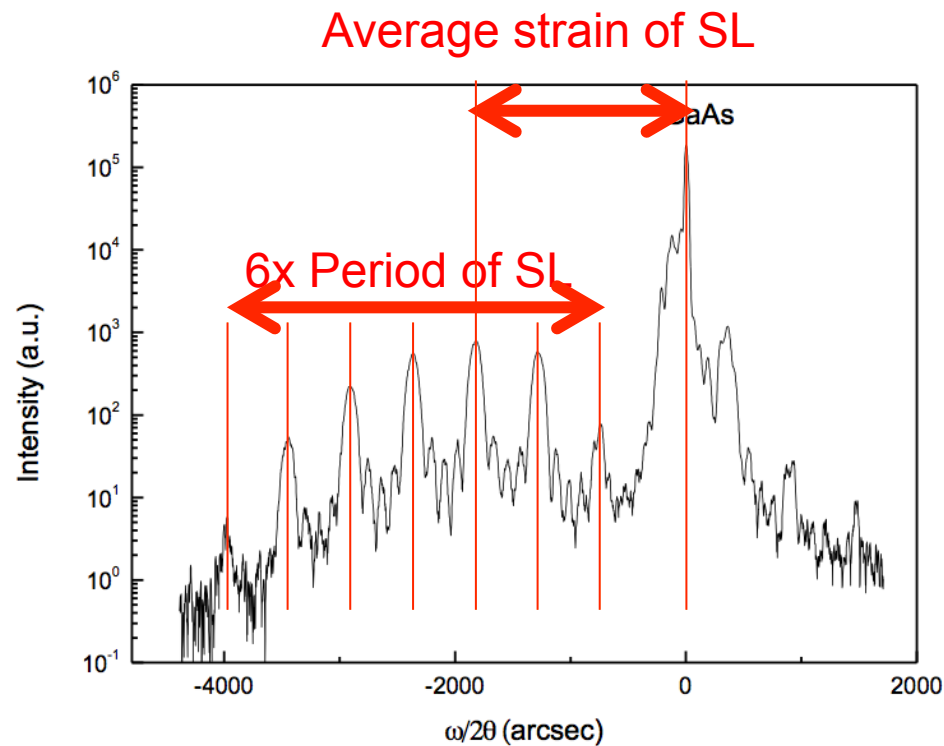




Example X-Ray Diffraction



Superlattice - X-Ray



Substrate peak

Zero-order peak – addition of Bragg reflections from A and B components of superlattice. Average composition of A + B layers can be obtained by differentiation of Bragg's law.

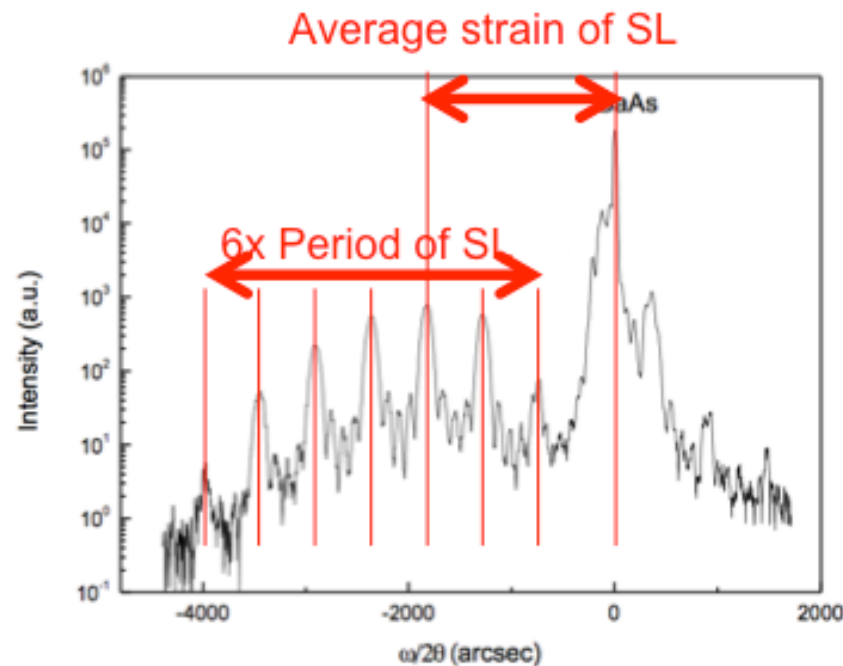
Satellite peaks – spacing determined by periodicity of superlattice

Your Test Samples

Repeats	Thickness	Thickness tolerance	Material	Material tolerance	Doping type	Doping level	Doping tolerance
1	20.0 nm		GaAs		Undoped	0.0	cm ⁻³
1	50.0 nm		Al _(0.3) Ga _(0.7) As		Undoped	0.0	cm ⁻³
1	25.0 nm		GaAs		Undoped	0.0	cm ⁻³
5	25.0 nm		GaAs		Undoped	0.0	cm ⁻³
5	8.0 nm		In _(0.12) Ga _(0.88) As		Undoped	0.0	cm ⁻³
1	50.0 nm		GaAs		Undoped	0.0	cm ⁻³
1	50.0 nm		Al _(0.3) Ga _(0.7) As		Undoped	0.0	
1	200.0 nm		GaAs		Undoped	0.0	
1	1.0 nm		-		Undoped	0.0	

Various [In],
thicknesses

Your Experiment...



Substrate peak

Satellite peaks –spacing will change as QW width is varied

Zero-order peak – As period changes, so average strain of SL changes

What You Will Do

- Measure X-Ray diffraction curve for your wafers
 - Deduce the period of your superlattice (assumption that GaAs growth rate doesn't change)
 - Deduce the indium composition of your QW
 - Explore reasons for the shape of the curve
- Measure PL spectrum of your wafers
 - Discuss the form of the spectrum
 - Knowing the indium composition, determine the quantum well width
- Write a report
 - Describe background of PL measurement, X-Ray diffraction, and your measurements

When, Where?

- Experiments will take ~2 hours in the Nano-Science Cleanrooms, North Campus
- Monday February 9th – 3PM
- Tuesday February 10th – 3PM
- Friday February 13th – 3PM
- Monday February 16th – 3PM
- Tuesday February 17th – 3PM
- Friday February 20th – 3PM
- DON'T BE LATE....Be in reception at Centre for Nanoscience and Technology at this time....You are advised not to wear a skirt!

How?

- You take the data as a team and have a good long think....
- We will provide a pro-forma template which forms the back-bone of your report and prompt some questions
- You need to describe the experimental procedures, plot graphs (please spend time to do this professionally), process data, draw conclusions and speculate on the interpretation of your data
- The report is worth 25% of the module marks
- Be aware of plagiarism rules and regs.....
- TurnItIn is very efficient.....Don't be a fool....
-Good luck!